

HIPIMS-ITO from Cylindrical Cathodes

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Motivation: HIPIMS-ITO

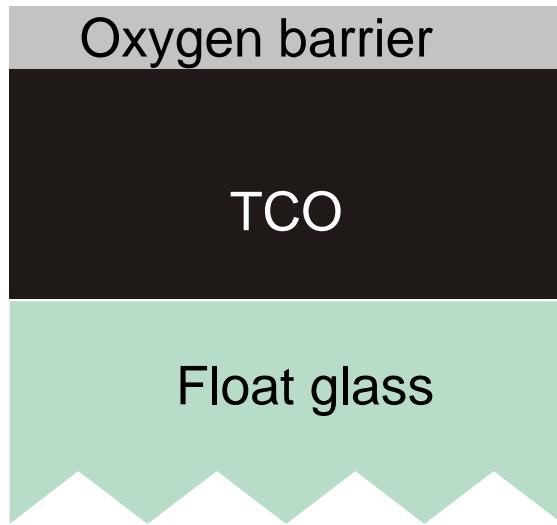
Movie: [ice-free windshield](#)

Outline

- Motivation
- HIPIMS ITO-process
 - Process parameters
 - Resulting properties
 - Which HIPIMS-Power Supply to use?
- Use of cylindrical cathodes
 - Motivation
 - Demand of HIPIMS process
- Potential Applications

Layer stack and design of experiments for ITO HiPIMS

Low-E Stack



← SiO_xN_y : thickness ~40 nm

← ITO: thickness ~140 nm

Layer stack was annealed at 650°C (10 min / air)

Investigations on:

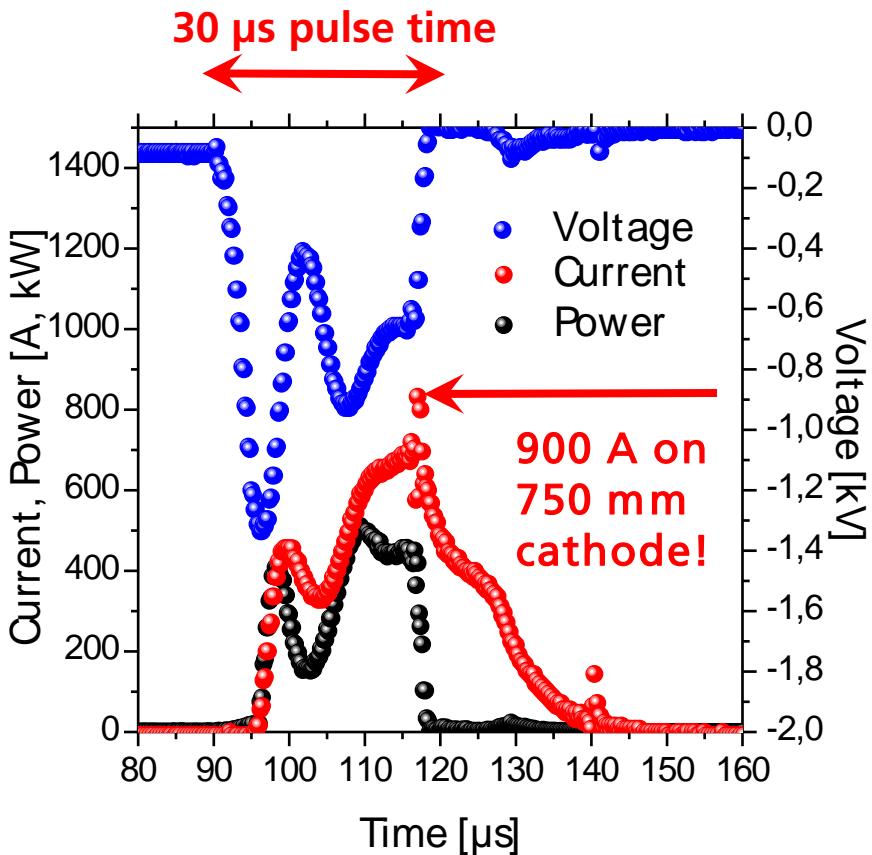
- Charge voltage
- Pulse length (t_{on})
- Arc controlling

Demands:

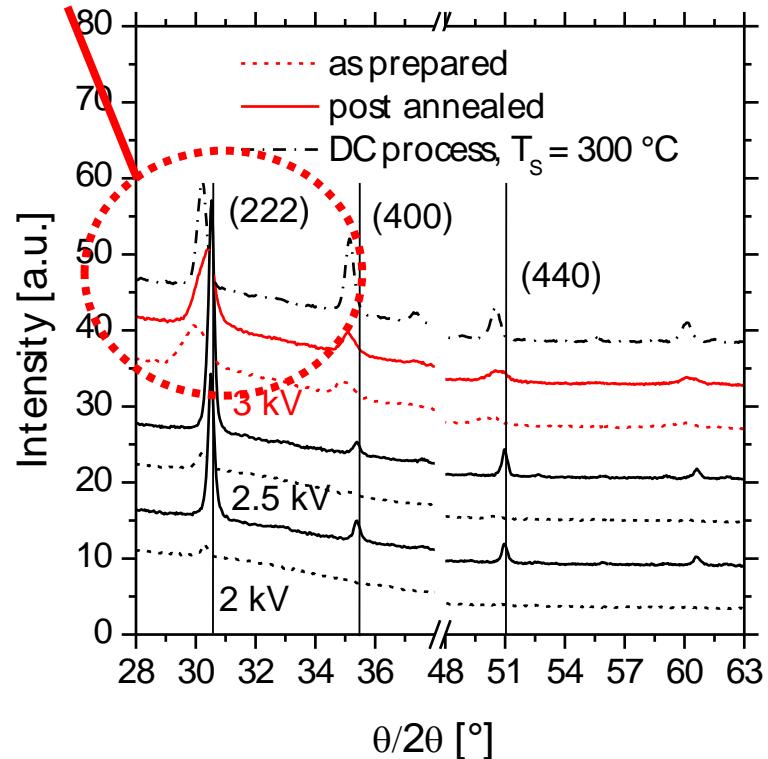
- Mechanical and chemical resistant Low-E coating for pos. 1
- Low-E coating with $\epsilon < 0.30$
- Visible light transmittance $T_{\text{vis}} > 80 \%$

ITO HiPIMS using an experimental power supply #2

Short pulse HiPIMS for nc-ITO with extraordinary stability



Stable nanocrystalline films during annealing at 650 °C / 10 min / air

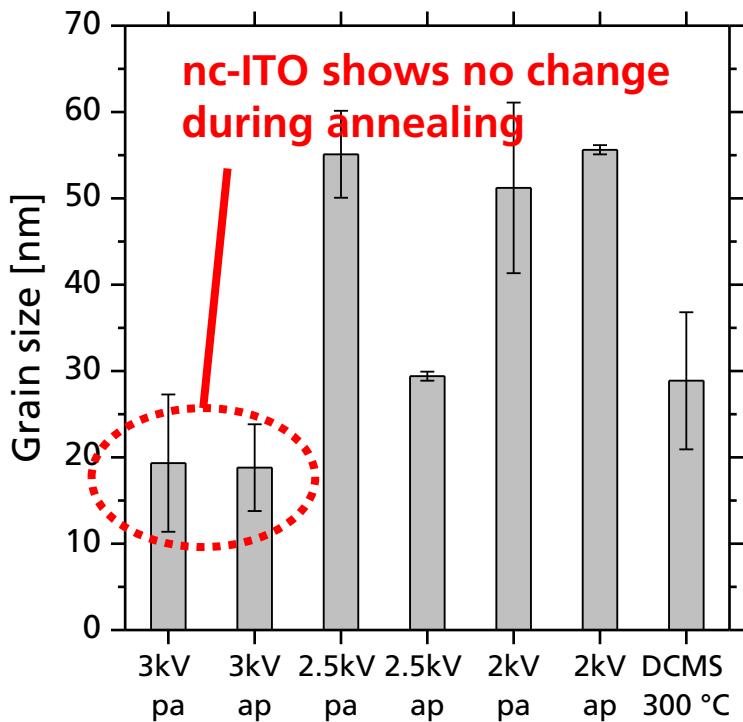


■ Growth of nanocrystalline ITO due to short pulse HiPIMS at $U_C = 3$ kV

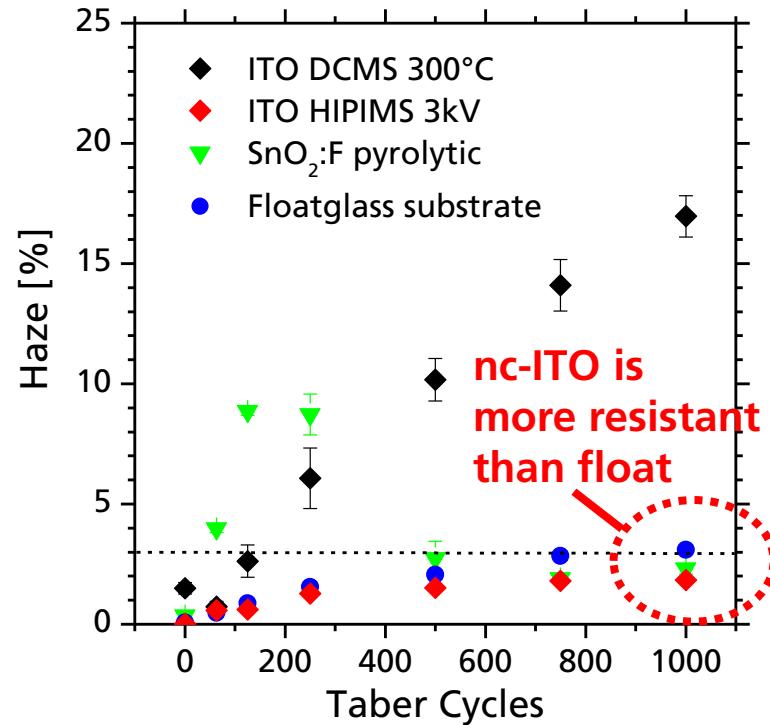
F. Horstmann et al., TSF 517 (2009) 3178 | DE 10 2008 028 140 B3

Criteria for the evaluation of ITO HiPIMS coatings

a) Grain size analysis by Scherrer



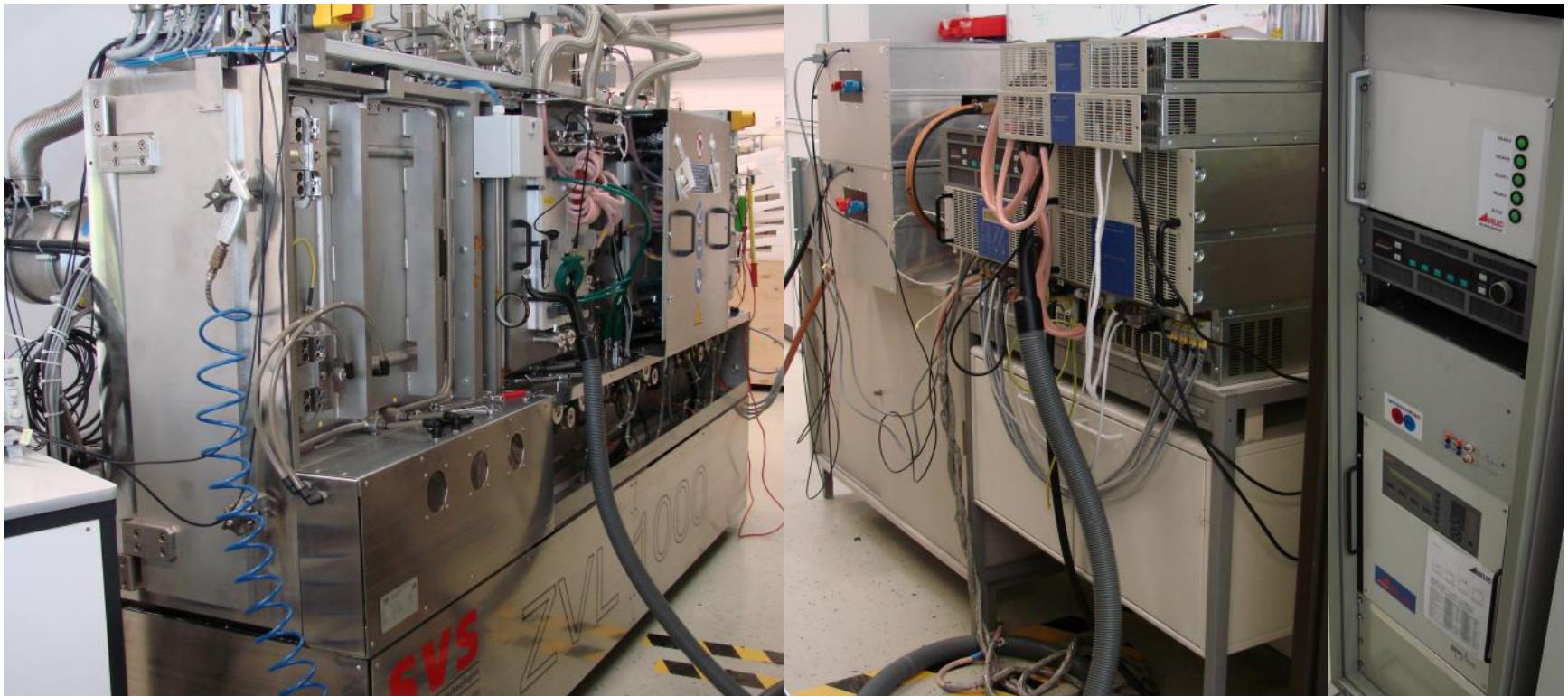
b) Taber test and stray light



- Phase stability correlates with haze post annealed

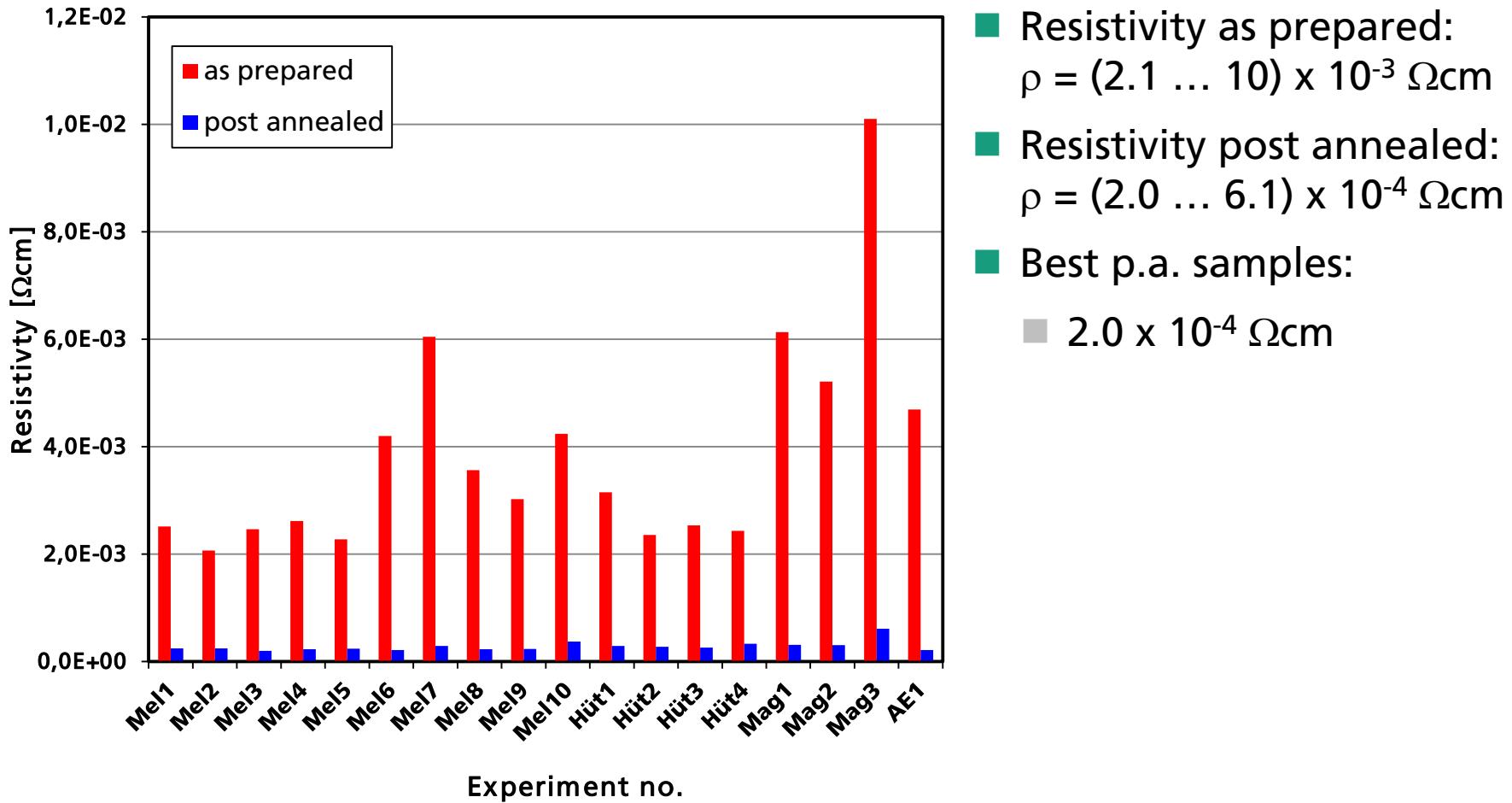
- Taber test post annealed & haze measurement

Arrangement of HIPIMS power supplies



- Magpuls prototype
- Hüttinger TruPlasma Highpulse 4008
- MELEC SIPP
- Advanced Energy prototype (at Leybold A700V)

Sheet resistance (four point and eddy current)



Influence of HiPIMS Power Supply

- Short pulse HiPIMS
 - Pulse length in the order of 30 µs can be reached by all power supplies investigated.
 - Proper arc handling at high power conditions is the crucial point.
- ITO film properties
 - ITO films for coat & bend processes can be realized with commercially available HiPIMS power supplies.
 - Arc quenching is different and might be the reason for differences in film quality.
 - Fine tuning of parameter range is necessary.
 - Successful solutions with all HiPIMS power supplies possible.

Use of Cylindrical Cathodes

Planar vs. Rotatable

- Higher average power possible
- Higher utilization (same thickness)

Planar	Cylindrical
Width: 150 mm	$\varnothing: 150 \text{ mm}$ $d * \pi = 470 \text{ mm}$
Utilization: 30-40%	80-90%
Lifetime	6x Planar

Especially when using expensive materials more cost efficient
(than reclaim: time consuming; costly)



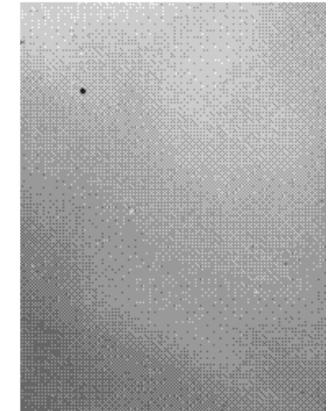
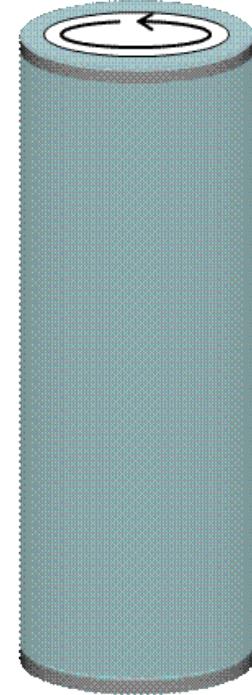
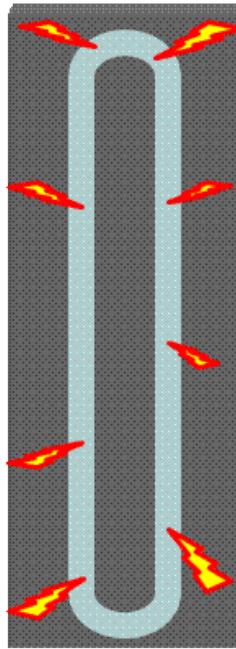
Source: Angstrom Sciences

Use of Cylindrical Cathodes

Planar vs. Rotatable

- Reduced arcing

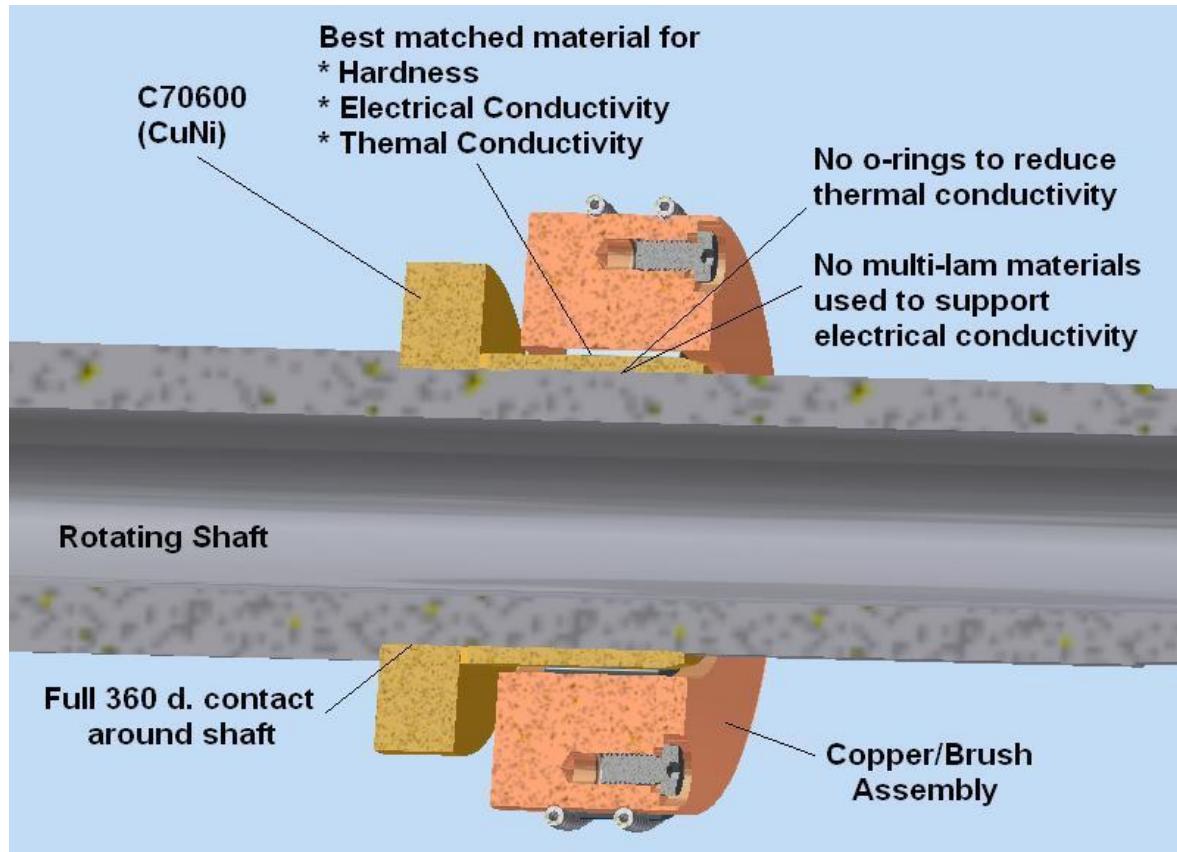
- nearly no re-deposition zones
- reduced nodule growth



Use of Cylindrical Cathodes

Demand for HIPIMS

- High peak current required

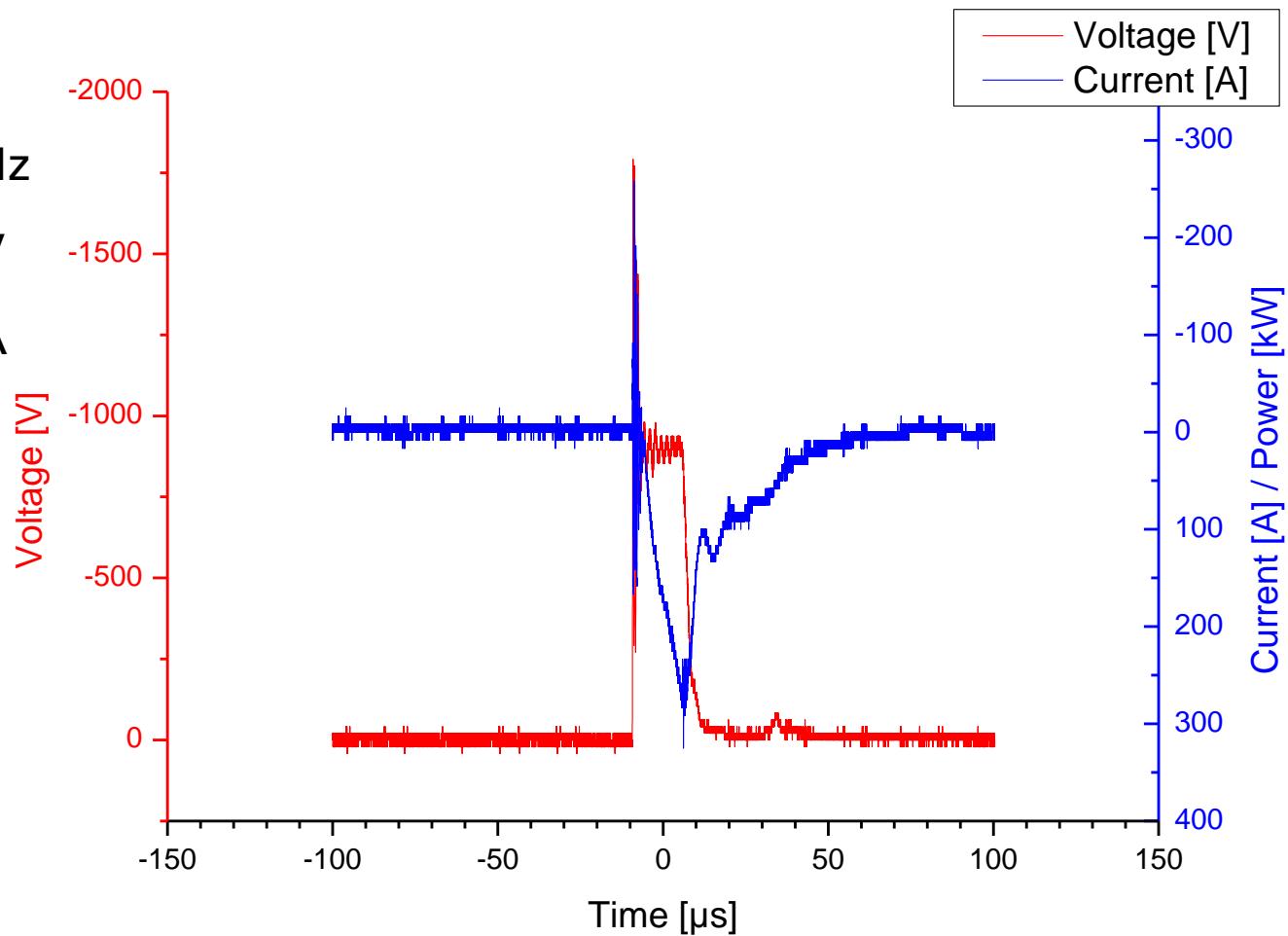


Source: Angstrom Sciences

Voltage – Current Behavior

Cylindrical Cathodes

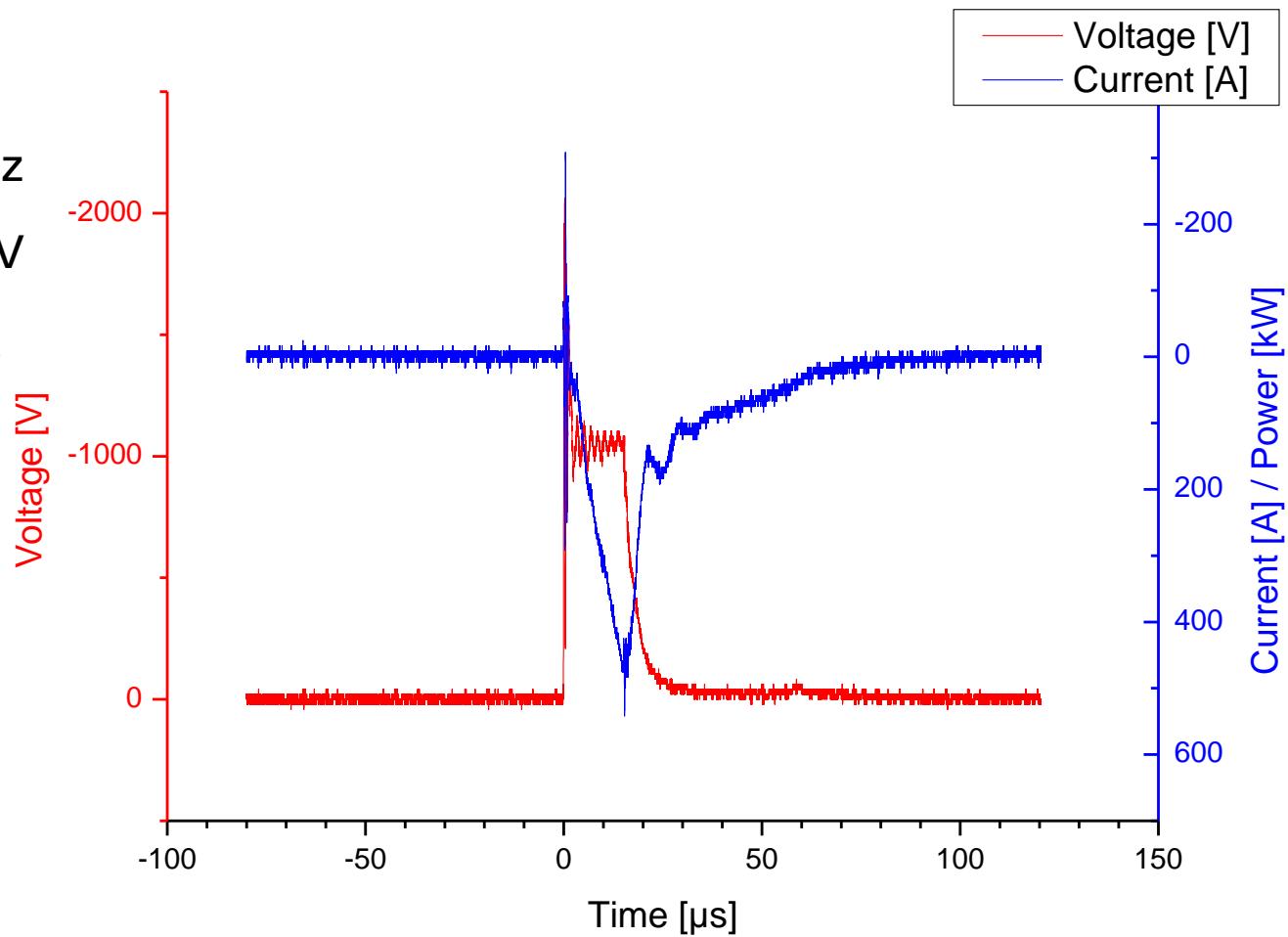
- t_{on} : 15 μ s
- f: 128 Hz
- U_{Charge} : 900 V
- I_{peak} : 300 A



Voltage – Current Behavior

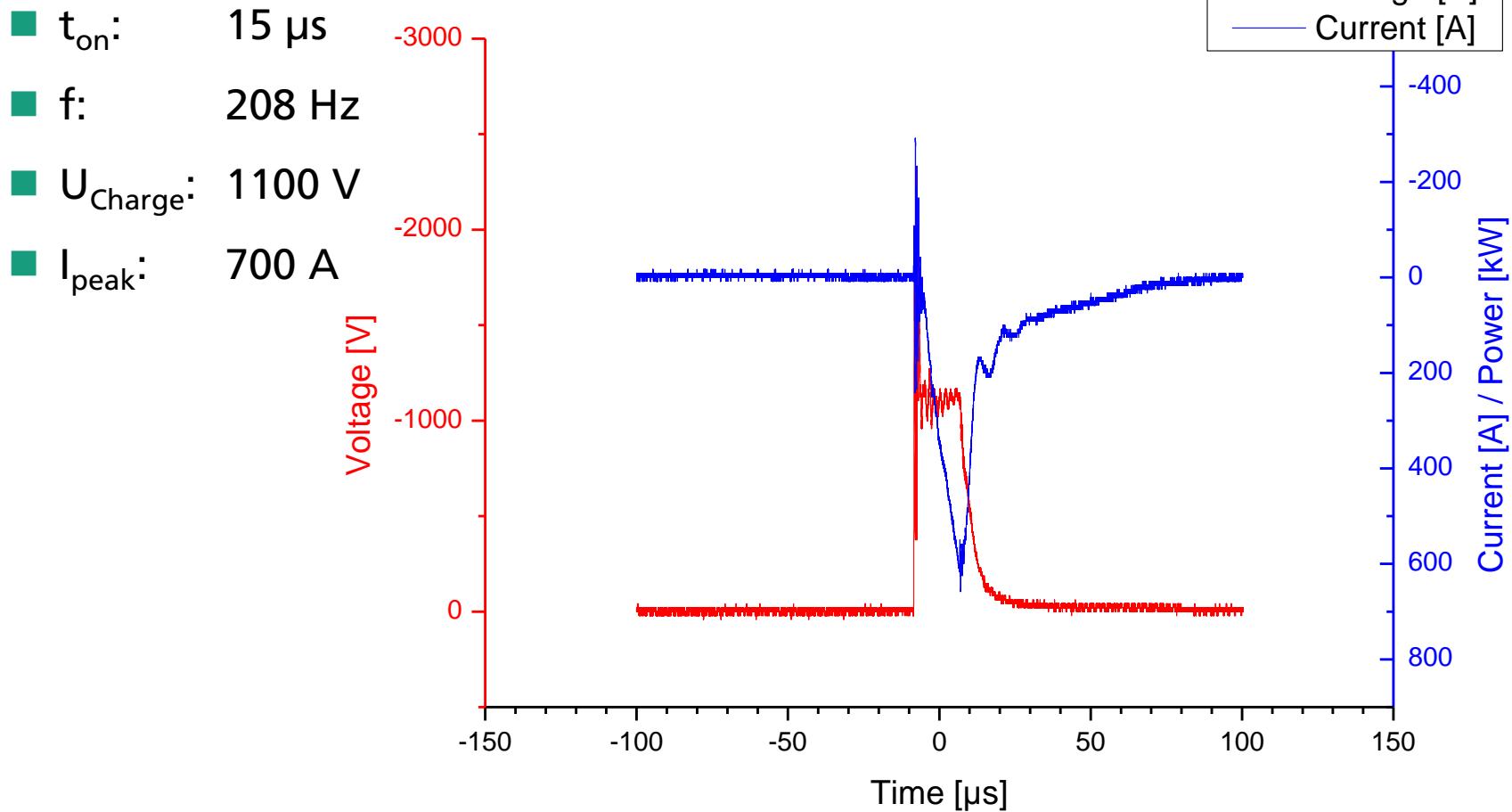
Cylindrical Cathodes

- t_{on} : 15 μ s
- f: 320 Hz
- U_{Charge} : 1050 V
- I_{peak} : 500 A



Voltage – Current Behavior

Cylindrical Cathodes



Applications

Functional films - ITO

HIPIMS-ITO

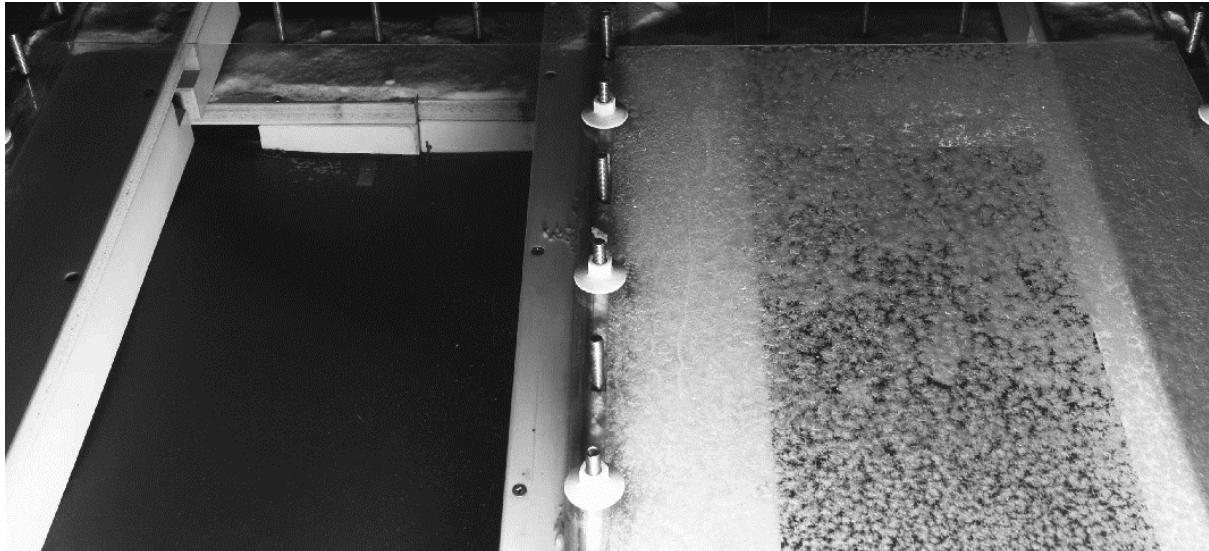
- Room temperature process
 - Excellent properties on complex shaped parts
 - Improved scratch resistance (pos. 1 application)
-
- ➔ Displays, Touch panels
 - ➔ Solar cells (e. g. nano carpets)
 - ➔ Architectural glazing (low E-coatings)
 - ➔ Ice-free windshields (automotive, aerospace, ...)
 - ➔ Transparent heating (heatable)

HIPIMS Applications

Functional films - ITO

Ice-free windshield

- Short pulses prevent arcing
- High peak current
- Nano crystalline coating



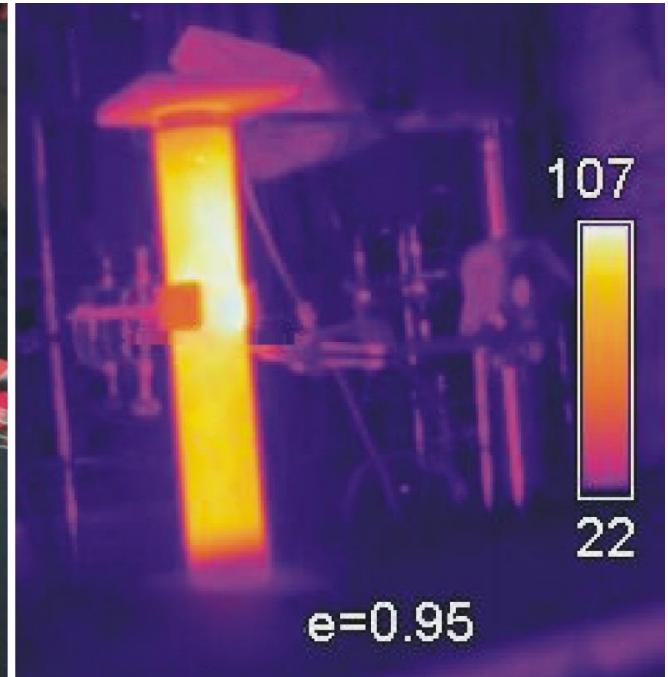
coated

uncoated

HIPIMS Applications

HIPIMS processes: ITO

- HIPIMS ITO
- Deposition on shaped glass (glass tubes)
- Thermal image of a heating coating on a glass tube from the BASF Group for protective heating in distillation columns



Source: Fraunhofer IST, BASF AG

- Uniform heating of liquids in distillation columns
- Heat insulating effect due to low emissivity

Acknowledgement

The authors gratefully acknowledge the support of the planar target process development by:



and for the tube target process development by:



HÜTTINGER Elektronik
generating confidence



Thank you for your attention!

Get your
sample of
our
HIPIMS-Tea

Booth 434



Love never fails.
... where there is knowledge, it will pass away.

1. Corinthians 13,8